Light-Induced Surface Reactions at the Bismuth Vanadate/Potassium Phosphate Interface

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ABSTRACT: Bismuth vanadate has recently drawn significant research attention as a light-absorbing photoanode due to its performance for photoelectrochemical water splitting. In this study, we use in situ ambient pressure X-ray photoelectron spectroscopy with “Tender” X-rays (4.0 keV) to investigate a polycrystalline bismuth vanadate (BiVO₄) electrode in contact with an aqueous potassium phosphate (KPi) solution at open circuit potential under both dark and light conditions. This is facilitated by the creation of a 25 to 30 nanometers thick electrolyte layer using the “dip-and-pull” method. We observe that under illumination bismuth phosphate forms on the BiVO₄ surface leading to an increase of the surface negative charge. The bismuth phosphate layer may act to passivate surface states observed in photoelectrochemical measurements. The repulsive interaction between the negatively charged surface under illumination and the phosphate ions in solution causes a shift in the distribution of ions in the thin aqueous electrolyte film, which is observed as an increase in their photoelectron signals. Interestingly, we find that such changes at the BiVO₄/KPi electrolyte interface are reversible upon returning to dark conditions. By measuring the oxygen 1s photoelectron peak intensities from the phosphate ions and liquid water as a function of time under dark and light conditions, we determine the timescales for the forward and reverse reactions. Our results provide direct evidence for light-induced chemical modification of the BiVO₄/KPi electrolyte interface.
Introduction

Chemical fuels produced using sunlight is a potential way to store solar energy and therefore mitigate its intermittency.\(^1, 2, 3, 4, 5, 6, 7\) To date, solar fuel research has predominantly focused on solar water splitting to generate hydrogen, which can be used both as a primary energy source (in power plant or automobile-based fuel cells) and as a chemical feedstock for the production of synthetic fuels.\(^7, 8, 9, 10, 11, 12, 13, 14\) During photoelectrochemical water splitting, sunlight absorbed by a semiconductor generates photo-excited charge carriers, (electrons in the conduction band (CB) and holes in the valence band (VB)) that drive electrochemical reactions at the semiconductor/aqueous electrolyte interface. The electrons drive hydrogen evolution at the cathode while holes drive oxygen evolution at the anode. Since the rate of photoelectrochemical water splitting is determined by charge separation and hole transfer from the anode to the electrolyte, research efforts focus mainly on photoanode materials for oxygen evolution.

Among the promising photoanode materials for solar water splitting, monoclinic clinobisvanite bismuth vanadate (BiVO\(_4\)) has recently drawn significant research attention due to its high photo-activity, good catalytic properties and reasonable stability.\(^7, 9, 10, 15, 16, 17, 18, 19\) The valence band maximum (VBM) of BiVO\(_4\), an \(n\)-type semiconductor, is lower than the oxygen evolution potential (+1.23 V vs. NHE at pH 0), allowing holes to be efficiently transferred to the electrolyte and subsequently oxidize water. However, charge carrier recombination at the semiconductor/electrolyte interface limits the efficiency of BiVO\(_4\) based devices by eliminating holes before they can oxidize water.\(^20, 21\) Surface states induced by surface reactions can act as electron and hole traps and enhance the recombination rate. Moreover, surface states are well-known to cause Fermi level pinning leading to reduced photovoltages and a decrease in the efficiency of the device.\(^22\) Therefore, a detailed understanding of the chemical composition of the semiconductor/aqueous electrolyte interface and its dependence on specific conditions (applied potential and illumination) would provide valuable input for the optimization of photoanode material for oxygen evolution.\(^23, 24\)

In this study, we investigate a polycrystalline, undoped BiVO\(_4\) photoanode/potassium phosphate (KPi) aqueous electrolyte interface. Capacitive current scans reveal that a surface state present on undoped BiVO\(_4\) in the dark is quenched under illumination. Using \textit{in situ} ambient pressure hard X-ray photoelectron spectroscopy (AP-HAXPES) with 4.0 keV excitation energy, we have investigated chemical transformations at the BiVO\(_4\)/KPi interface induced by solar light at the half-cell open circuit potential. To conduct such measurements, a 24 to 32 nanometers thick
KPi aqueous electrolyte layer is created by the “dip-and-pull” method.\textsuperscript{25, 26, 27, 28, 29, 30, 31} We show that a thin layer of bismuth phosphate (BiPO\textsubscript{4}) is formed on the BiVO\textsubscript{4} surface under illumination which likely acts to passivate surface states. Time dependent AP-HAXPES measurements suggest that an increase of the surface negative charge as a function of the illumination time, as measured by a change in the half-cell open circuit potential, is correlated with the formation of the BiPO\textsubscript{4} layer. The repulsive interaction between the negatively charged surface and the phosphate anions in the electrolyte solution causes a change in the distribution of ions in the aqueous electrolyte layer. This is observed as an increase in the photoemission signal from the ions in solution. Interestingly, we find that such changes are reversible upon returning to dark conditions. Our findings provide direct evidence of light-induced chemical modification of the BiVO\textsubscript{4}/KPi electrolyte interface.

**Experimental**

*Sample preparation*

Undoped BiVO\textsubscript{4} thin films were prepared by spray pyrolysis on FTO-coated glass (TEC-15, Pilkington). Detailed information on the spray pyrolysis setup and precursor solutions can be found in our previous report.\textsuperscript{32} In short, the FTO substrate was placed on a hot plate (450° C) during the spray pyrolysis of BiVO\textsubscript{4}. 100 cycles of deposition were performed with a rate of \(-1\) nm per cycle. Prior to the BiVO\textsubscript{4} deposition, 5 mL solution of 0.1 M SnCl\textsubscript{4} (99\%, Acros Organics) in ethyl acetate (99.5\%, J.T. Baker) was sprayed on the FTO substrate to form a SnO\textsubscript{2} interfacial layer (~80 nm). Finally, the undoped BiVO\textsubscript{4}/SnO\textsubscript{2}/FTO sample was post annealed for 2 hours at 450° C under the flow of technical air (80\% N\textsubscript{2}/20\% O\textsubscript{2}). The surface morphology of the obtained samples was studied by atomic force microscopy in tapping mode, as reported in Figure S1.

*Photoelectrochemical measurements*

The chemicals were high purity reagents and used without further purification. MilliQ water (DI, \(\rho=18.2\) M\(\Omega\cdot\text{cm}\)), K\textsubscript{2}HPO\textsubscript{4} and KH\textsubscript{2}PO\textsubscript{4} (99.95\% and 99.99\%, Aldrich, respectively) were used as the solvent and supporting electrolyte, respectively. The 0.1 M KPi solution was made by dissolving 0.062 mol of K\textsubscript{2}HPO\textsubscript{4} and 0.038 mol of KH\textsubscript{2}PO\textsubscript{4} per liter of MilliQ water. The measured pH of the KPi solution was between 7.0 and 7.1.

The counter electrode (CE, Pt polycrystalline foils, 99.99\%, thickness 0.5 mm, Aldrich) was polished to a mirror finish with silicon carbide paper of decreasing grain size (Struers, grit: 2400 and 4000). The CE was then cleaned with two cycles of ultrasonic treatment in a mixture of MilliQ water/ethanol (Aldrich, 1:1) for 10 min. A third ultrasonic cleaning was then conducted in pure MilliQ water for 15 min, followed by a thorough rinsing and drying in streaming N\textsubscript{2}(g). The reference electrode (RE), was a miniaturized leak-less saturated Ag/AgCl/Cl\textsubscript{(sat.)} RE (ET072-1, eDAQ, standard electrode potential \(E^\circ_{\text{Ag}/\text{AgCl}}(\text{sat.}) = +199\) mV with respect to the normal hydrogen electrode, NHE). For better comparison to the literature, the potentials reported in this work are referred to the reversible hydrogen electrode (RHE), which is related to the Ag/AgCl/Cl\textsubscript{(sat.)} electrode and the electrolyte pH by the following relation:

\[
E_{\text{RHE}} = E_{\text{Ag}/\text{AgCl}}(\text{sat.}) + E^\circ_{\text{Ag}/\text{AgCl}}(\text{sat.}) + 0.0591 \cdot \text{pH}
\]
Cyclic voltammetry (CV) measurements were conducted at room temperature at a scan rate of 10 mV s\(^{-1}\) in a 0.1 M KPi solution. Capacitive current scans were used to determine the surface charge and the BiVO\(_4\)/KPi electrolyte interfacial differential capacitance (i.e. capacitance as a function of the applied potential). The measurements were carried out at room temperature. The charge was determined by integrating the area of the cyclic voltammetry curves (taken with a scan rate of 50 mV s\(^{-1}\)) within a 20 mV potential window centered at each chosen potential.\(^{28, 33}\) The results are reported in Figure S2.

**In situ hard X-ray photoelectron spectroscopy measurements**

**Beamline 9.3.1 and AP-HAXPES experimental details**

The source for beamline 9.3.1 at the Advanced Light Source (ALS) of Lawrence Berkeley National Laboratory is a bending magnet. A Si(111) double crystal monochromator (DCM) provides an energy range between 2.0 keV and 7.0 keV (i.e., the “tender” X-ray range, denoted as “hard” throughout the text to be consistent with the acronym HAPXES). The minimum X-ray spot size on the sample is 0.7 mm (v) × 1.0 mm (h). All spectra were taken with a photon energy of 4.0 keV, at room temperature and in normal emission (NE). The pressure in the experimental chamber was kept at the equilibrium vapor pressure of the KPi electrolyte solution at room temperature. The pass energy of the Scienta analyzer (R4000 HiPP-2) was set to 200 eV. A step size of 100 meV and a dwell time of 300 ms was used. Under these conditions, the total resolution (X-ray plus analyzer) was equal to about 700 meV at 4.0 keV. To limit evaporation from the electrochemical cell a large volume (~ 500 mL) of outgassed pure water was introduced in the analysis chamber. The Shirley background was optimized together with the spectral components. \(^{34, 35, 36}\) Finally, chi-square (\(\chi^2\)) minimization was ensured by the use of a nonlinear least squares routine, with increased stability over simplex minimization.

**“Dip and pull” method and in situ measurements**

Three electrodes (BiVO\(_4\) WE, Ag/AgCl/Cl\(^{-}\)\((\text{s}at.)\) RE and Pt foil CE) were mounted in a PEEK electrode housing that was attached to a multi-axis manipulator. The working electrode (WE), counter electrode (CE), and reference electrode (RE) were connected to an external potentiostat/galvanostat (Biologic SP 300) to perform in situ electrochemical measurements. During operation, the WE and the electron energy analyzer were commonly grounded.

Prior its introduction into the experimental chamber, the 0.1 M KPi aqueous electrolyte was outgassed for at least 30 min at low pressure (between 10 and 20 Torr) in a dedicated off-line chamber. The pH of the 0.1 M KPi solution was measured to be between 7.0 and 7.1. After degassing the electrolyte solution, it was placed into the AP-HAXPES chamber, the pressure was carefully decreased to just below the equilibrium vapor pressure of the 0.1 M KPi solution at room temperature, and then pumping was stopped and the chamber pressure drifted up to the equilibrium vapor pressure of the KPi electrolyte solution at room temperature (approximately 17 Torr).

To create the BiVO\(_4\)/KPi electrolyte interface (WE/electrolyte), all three electrodes were immersed deeply into the electrolyte. They were then slowly extracted from the electrolyte solution by raising the manipulator at a slow and constant rate. Following this procedure, a thin layer of the KPi aqueous electrolyte film is formed on the electrode surface (typical values in this study are 24 to 32 nm, see below); the BiVO\(_4\) working electrode was then positioned at the intersection of the X-ray beam and the focal point of the hemispherical electron analyzer (HEA), thereby allowing AP-HAXPES measurements of the BiVO\(_4\)/KPi electrolyte interface. During the measurements, the bottom parts of the electrodes remained submerged in the bulk KPi electrolyte solution, in order to ensure electrical continuity between the thin electrolyte layer on the BiVO\(_4\) WE surface and the bulk KPi electrolyte.
To illuminate the BiVO$_4$/KPi system during the AP-HAXPES experiments, a solar simulator (Asahi Spectra, HAL-C100) was used as a light source (sun irradiation: 1 sun = 75 mW cm$^{-2}$). The light source, whose power density was distributed over a spectral range from 350 nm to 1100 nm, was placed at a distance of about 25 cm from the BiVO$_4$ WE (front illumination configuration), and the light was directed to the sample through a standard CF35 windowed flange (glass thickness: 3 mm). Under such conditions, the maximum power was reached in a 10×10 mm$^2$ sample area, with an average power density of about 69 mW cm$^{-2}$ (~ 0.92 sun) at the WE surface.

**Results**

**BiVO$_4$ film morphology**

The surface morphology of the BiVO$_4$ film was studied with atomic force microscopy (AFM, see inset in **Figure 1** and also SI Figure S1) which provided a root mean square (RMS) roughness of about 25 nm over an area of 2×2 µm$^2$.

**Photoelectrochemical measurements on BiVO$_4$**

To determine the BiVO$_4$/KPi electrolyte interface capacitance ($C_{\text{BiVO}_4/\text{KPi}}$)$^{37}$ as a function of the applied potential under dark and light conditions the electrochemical capacitive current scan method was used (see Experimental section and **Figure S2** for the capacitive current determination under dark and light conditions via cyclic voltammetry). The capacitance determined under dark conditions exhibits a pronounced deviation from the typically observed asymptotic decay, which reflects a decrease in space charge width with increasing applied potential (**Figure 1**). Instead it shows a peak centered at about +0.7 V vs. RHE. Such a peak has been previously characterized as evidence for a surface state by Bard et al.$^{22}$ The surface state can cause unpinning of the band edges and, consequently, Fermi edge pinning across the BiVO$_4$/KPi electrolyte interface and can have a detrimental effect on device efficiency.$^{20, 22}$ **Figure 1** shows that to unpin the Fermi edge in dark conditions the applied potential must exceed ~1 V vs. RHE. This is consistent with previous reports for undoped BiVO$_4$.$^{20}$ Interestingly, when we illuminate the BiVO$_4$ with solar light, the feature associated with the surface state in the capacitance versus applied potential plot disappears (only the typical asymptotic decay remains, see **Figure 1**) but reappears after returning to dark conditions. This suggests that the surface state present on the pristine undoped BiVO$_4$ in dark conditions is passivated upon illumination.

Surface state passivation on BiVO$_4$ photoanodes has been previously observed when depositing catalyst layers. For example, using intensity modulated photocurrent spectroscopy to monitor the rates of charge transfer and recombination, Zachäus et al. observed a decrease in the
The decrease in the recombination rate constant was attributed to surface state passivation by the deposited cobalt phosphate layer. The study by Zachäus et al. demonstrates that deposition of an overlayer can passivate surface recombination centers and lead to increased device performance. Our results, however, imply that surface state passivation can occur under illumination for the pristine BiVO$_4$ surface which Zachäus et al. did not observe. This apparent discrepancy may simply be the result of the different light intensities used in the two studies. The intensity of light used in our study is about 25 times higher than that used by Zachäus et al. Since the surface state passivation observed here is associated with BiVO$_4$ illumination we would expect to have significantly more passivation than Zachäus et al. due to the much higher light intensities used. Analogous to using overlayer deposition to passivate surface states as in the case of Zachäus et al., in the present study illumination of the BiVO$_4$ may drive interfacial chemical reactions that effectively lead to the deposition of a passivating overlayer. Indeed, Trzésniewski et al. recently reported a light-soaking treatment that suppresses surface recombination in BiVO$_4$.

In order to investigate light driven chemistry at the BiVO$_4$/KPi electrolyte interface
and to test this hypothesis we have conducted in situ AP-HAXPES measurements which allows for direct chemical interrogation of solid/liquid interfaces.

**In situ AP-HAXPES at the BiVO₄/KPi interface**

In order to gain chemical information about the BiVO₄/KPi aqueous electrolyte interface, we performed in situ AP-HAXPES using the “dip and pull” technique available at the Advanced Light Source at beamline 9.3.1 (Figure 2a). We studied the chemical composition of both the BiVO₄ surface and KPi electrolyte as a function illumination and time. The measurements were conducted at the half-cell open circuit potential (OCP) to monitor chemical changes induced exclusively by illumination with the solar simulator. We monitored O 1s and Bi 4f photoelectron spectra as well as additional peaks related to the species in the electrolyte solution, namely the K 2p and P 2p spectra. Figure 2b shows selected O 1s spectra for the pure

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**Figure 2.** In situ AP-HAXPES experiments performed on a poly-crystalline BiVO₄/liquid electrolyte interface. Figure a shows digital photographs of the different phases of the experiment, such as the “dip and pull” procedure (top) and the AP-HAXPES measurements under dark and light conditions (bottom). HEA: hemispherical electron analyzer, note that in the top two photographs the view is from behind the sample towards the entrance aperture to the HEA; b: selected O 1s spectra and corresponding multipeak fitting procedure, I. KPi electrolyte only, II. the BiVO₄/KPi electrolyte system initially in the dark, III. the BiVO₄/KPi electrolyte system after 1000 s of illumination with a solar simulator, IV. The BiVO₄/KPi electrolyte system 1200 s after returning to dark conditions.
KPi electrolyte (Figure 2b, I), and the BiVO$_4$/KPi electrolyte system in the dark and under illumination (Figure 2b, II, III, and IV). The O 1s photoelectron signal acquired for a thick electrolyte film (Figure 2b, I) can be de-convoluted into three different components: gas phase water (GPW) at about 536 eV, liquid phase water (LPW) at about 533.5 eV and solvated phosphate ions (HPO$_4^{2-}$ and H$_2$PO$_4^-$, labelled as H$_x$PO$_{y}$), at about 531.4 eV. The same de-convolution can be used to analyze the O 1s spectra acquired for the BiVO$_4$/KPi interface, under dark and light conditions with the addition of a new component centered at a binding energy of about 529.7 eV. This peak arises from the O$^{2-}$ anions of the BiVO$_4$ (Figure 2b, II).

The thickness of the KPi aqueous electrolyte layer on the BiVO$_4$ surface can be estimated using the ratio of the oxide to LPW O 1s peak intensities. We used Monte Carlo simulations of the photoelectron intensity implemented in the SESSA software package$^{41}$ to model the oxide to LPW ratio. We can then compare the model calculation results to the ratios determined by the multipeak fitting procedure reported in Figure 2b. The results of this analysis are reported in Figure S3. We used two different models: 1) a model with a flat BiVO$_4$ surface and 2) a BiVO$_4$ surface with a morphology more closely resembling the actual one where the model surface is based on the topography profiles reported in Figure S1. The two different surface models lead to similar results (Figure S3). Comparing the ratios found in the model to the experimentally determined ratios (0.056 in Figure 2b II, 0.012 in Figure 2b III and 0.019 in Figure 2b IV) shows that the electrolyte layer thickness was nearly constant throughout the experiment, with thicknesses ranging between 24 to 32 nm.

Interestingly, when passing from dark to light conditions, the H$_x$PO$_{y}$ component drastically increases in intensity (Figure 2b, II and III) relative to the intensity of the LPW O 1s peak. Moreover, despite the significant increase of the phosphate O 1s signal upon illumination, it decreases once dark conditions are restored (Figure 2b, III and IV). We note that upon illumination the binding energies of the O 1s peaks have shifted to slightly higher binding energies. The observed shifts are also reversible upon returning to dark conditions. These small shifts to higher binding energy of the O 1s spectra are consistent with a change in the open circuit potential to more negative values upon illumination (see below and refs. 23, 27, 28, 29, 30).

In addition to changes in the O 1s spectra, we also observe distinct changes in the AP-HAXPES signals arising from the ions in the electrolyte, as shown by the K 2p and P 2p core level spectra in Figure 3a and b, respectively. We observe a clear increase in the photoelectron
intensity from both K\(^+\) and P in the phosphate groups (H\(_2\)PO\(_4^–\)) when passing from dark to light conditions. This is highlighted by the difference spectra in Figure 3a and 3b. Similar to what is described above for the O 1s spectra, the increase in the signal intensity from the ions in the electrolyte upon illumination is reversible when restoring dark conditions.

Figure 3c shows Bi 4f photoelectron spectra for both dark and light conditions. Upon illumination the Bi 4f peak broadens to higher binding energy (Figure 3c, II). The addition of a second component at +0.7 eV higher binding energy from the main Bi 4f spectral feature (Bi\(^{3+}\), BE = 159.1 eV) allows quantification of the broadening. We note that the carbon contamination (BE ~ 285 eV) present is not affected when passing from dark to light conditions.

Finally, it was not possible to acquire the V 2p photoelectron peak under in situ conditions, due to the low intensity of the photoelectron signal. Figure S4 reports the Bi 4f, V 2p and O 1s photoelectron signals acquired before the dip and pull procedure at the BiVO\(_4\)/water vapor interface, at fully hydrated conditions (p\(_{\text{water}}\) ~ 18 Torr at room temperature) where the V 2p is clearly present.

**Discussion**

In this section, we rationalize the AP-HAXPES results reported above. First, we will discuss chemical changes of the BiVO\(_4\) induced by light, through an analysis of the broadening of the Bi
4f core level spectra. Secondly, we will analyze the time evolution of the H₃PO₄⁻ to LPW ratio to understand how the redistribution of ions in the thin electrolyte film is linked to the chemical modifications at the interface. Lastly, we will present a model that summarizes our results.

The *in situ* AP-HAXPES investigation of the BiVO₄/KPi aqueous electrolyte interface at the half-cell OCP shows that Bi 4f photoelectron peak undergoes a spectral broadening under illumination. This broadening was accounted for by adding a second component (centered at a 4f₇/₂ BE of 159.8 ± 0.1 eV) in addition to the main Bi³⁺ contribution (centered at a 4f₇/₂ BE of 159.1 ± 0.1 eV). Previous work has reported a Bi 4f₇/₂ BE of 159.8 ± 0.1 eV for bismuth phosphate.⁴², ⁴³, ⁴⁴, ⁴⁵ We note that a broadening of 0.7 eV is too large to be a result of band flattening alone. Previous studies have indicated an upward band bending of ~0.3 eV at the BiVO₄/KPi aqueous electrolyte interface suggesting that the largest amount of band flattening expected upon illumination is ~0.3 eV.¹⁶ In addition, core-level peaks should shift to higher binding energies and narrow with band flattening as opposed to the broadening observed here. Therefore, we assign the broadening of the Bi 4f peak under illumination to the formation of bismuth phosphate (BiPO₄). Note that we cannot quantitatively determine the number of phosphate groups per Bi atom using the P 2p or O 1s core-level intensities due to the large photoelectron signal intensity of the phosphate anions from the liquid electrolyte. Therefore, further experiments are required to determine the precise stoichiometry of the bismuth phosphate layer. The Bi 4f intensity ratio between the BiPO₄ and the Bi³⁺ components for the BiVO₄/KPi aqueous electrolyte system under illumination is equal to 0.62; or the BiPO₄ signal is 0.62/(0.62+1) = 0.38 of the total Bi 4f signal (see *Figures 3b*). We used the SESSA software package⁴¹ to estimate the thickness of bismuth phosphate that is necessary to account for this fraction of the total Bi 4f signal. Our estimate includes the following assumptions; 1) that the density of bismuth in the bismuth phosphate layer is the same as in BiVO₄, 2) that the bismuth phosphate layer is flat, and (3) that the bismuth phosphate layer covers the underlying BiVO₄ homogeneously. Under these assumptions we estimate that the bismuth phosphate layer formed under illumination is 2.3 nm thick. This thickness is equivalent to ~8 layers of BiVO₄ assuming a BiVO₄ layer thickness of 2.92 Å, which is ¼ the lattice constant in the [010] direction of crystalline BiVO₄.¹⁹, ²⁴ A possible mechanism for the formation of bismuth phosphate is photocorrosion of BiVO₄结合 with precipitation of bismuth phosphate from solution. If this is the case the growth bismuth phosphate will be self-limiting.

Bismuth phosphate is an *n*-type semiconductor with a wide band gap of 3.85 eV⁴⁵, ⁴⁶ and
possesses a large dipole due to the highly negative, polarizable, $\text{PO}_4^{3-}$ units. BiPO$_4$/BiVO$_4$ composites have shown enhanced visible-light photocatalytic activity for methylene blue degradation compared to either BiVO$_4$ or BiPO$_4$ alone. This has been attributed to the BiPO$_4$/BiVO$_4$ junction hindering electron-hole recombination, i.e. passivation of recombination centers upon BiPO$_4$ deposition. The formation of bismuth phosphate observed here may have a beneficial effect on the photoelectrochemical properties of BiVO$_4$ photoanodes in KPi solution similar to the passivating effects of cobalt layer deposition. This is suggested by the loss of the surface state feature observed in the capacitance versus applied potential plots upon illumination (Figure 1). However, since the bismuth phosphate layer may be formed via initial photocorrosion of BiVO$_4$ followed by BiPO$_4$ precipitation, controlling both the extent of photocorrosion as well as the thickness of the bismuth phosphate layer would be necessary to fully realize its potential.

**Figure 4.** Time evolution of the O 1s spectra at the half-cell open circuit potential (OCP) under illumination (a, ~0.92 sun) and after returning to dark conditions (c) (one spectrum every 40 s). Figures b and d show the phosphate ion (H$_x$PO$_y^-$) to liquid phase water (LPW) O 1s peak intensity ratio as a function of time found by integrating the areas under the peaks in the individual spectra in a and c using the multi-peak fitting procedure reported in Figure 2b. Also included in Figures b and d is the OCP as function of time. Corresponding time constants found by fitting to single exponential functions are provided in the figures.
beneficial effects.

We have investigated the time evolution of the light induced changes in the thin electrolyte film by plotting the $\text{H}_x\text{PO}_4^{y-}$ to LPW O 1s signal ratio as a function of time. The time-dependent O 1s spectra acquisition reported in Figure 4a and 4c, show the decay of the low binding energy tail as a function of time when passing from light to dark conditions. We have extracted time constants by fitting the ratio to a single exponential function, which assumes first order kinetics. This is shown in Figures 4b and 4d. For comparison we have also included in Figures 4b and 4d the time evolution of the half-cell OCP during the same time period with a similar single exponential fit. The time evolution for both the $\text{H}_x\text{PO}_4^{y-}$ to LPW O 1s signal ratio and the OCP match quite well and are fit with similar time constants suggesting that the changes in the two measured quantities are related to the same process. The change in the OCP indicates that upon illumination the surface becomes more negatively charged. This implies that the process that leads to the observed changes in the O 1s $\text{H}_x\text{PO}_4^{y-}$ to LPW signal ratio results in a more negatively charged surface. The extracted time constants are summarized in Table 1 showing that

### Table 1. Change in $\text{H}_x\text{PO}_4^{y-}$ to LPW O 1s signal intensity ratio and OCP time constants determined from the in situ AP-HAXPES and photoelectrochemical data.

<table>
<thead>
<tr>
<th>Fit Function</th>
<th>LIGHT</th>
<th>DARK</th>
</tr>
</thead>
<tbody>
<tr>
<td>$f(t) \propto \exp(-t/\tau)$</td>
<td>OCP</td>
<td>AP-HAXPES</td>
</tr>
<tr>
<td>$\tau(s)$</td>
<td>319 ± 4</td>
<td>321 ± 61</td>
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the time scale for the light induced changes at the interface is on the order of 100s of seconds for both the forward and reverse processes. This time scale allows us to eliminate some possibilities for the observed changes in the $\text{H}_x\text{PO}_4^{y-}$ to LPW O 1s signal ratio.

First, we note that the $\text{H}_x\text{PO}_4^{y-}$ to LPW O 1s signal ratio change can arise from two processes: 1) an increase in the $\text{H}_x\text{PO}_4^{y-}$ concentration in the thin electrolyte film upon illumination, or 2) a change in the distribution of $\text{H}_x\text{PO}_4^{y-}$ anions within the thin electrolyte film that shifts their average position closer to the electrolyte/vapor interface (XPS is always more sensitive to species closer to the surface since their photoelectrons are attenuated less\(^{47}\)). An increase in the concentration of phosphate ions in the BiVO$_4$/KPi system may be the result of BiPO$_4$ formation.
This is because, BiPO$_4$ formation may lead to a depletion of the phosphate ions in the thin aqueous electrolyte film and produce a phosphate ion concentration gradient that extends from the electrolyte in the beaker to the measurement position (see Figure 2a). This concentration gradient could provide a driving force for phosphate anions to diffuse from the beaker to the AP-HAXPES measurement position in order to re-establish the initial H$_3$PO$_4$$^{y–}$ anion concentration in the thin electrolyte film. The phosphate signal would then increase since the signal would be a sum of the phosphate in the BiPO$_4$ layer plus the H$_3$PO$_4$$^{y–}$ anions in the thin electrolyte film that have re-established their initial, dark conditions concentration. We can estimate the timescale for such a diffusion process by calculating the amount of phosphate ions in the bismuth phosphate film (and therefore the amount that has been depleted from the thin electrolyte film, 3.11 x 10$^{-9}$ mol of phosphate anions), using the known distance from the beaker to the AP-HAXPES measurement position (1 cm) and the diffusion constant for phosphate anions ($D = 7.9 \times 10^{-6} \text{ cm}^2 \text{ s}^{-1}$) in conjunction with Fick’s first law of diffusion. Note that the cross-section of the thin electrolyte film is small, about 0.7 cm x 30 x 10$^{-7}$ cm = 2.1 x 10$^{-6}$ cm$^2$. The results of such a calculation lead to timescales on the order of 10$^5$ s which is orders of magnitude longer than the 100s of seconds we observe. Therefore, it is highly unlikely that diffusion of phosphate anions from the beaker to the AP-HAXPES measurement position is responsible for the increase in the H$_3$PO$_4$$^{y–}$ to LPW O 1s signal ratio upon illumination.

Further, a timescale of 100s of seconds is far too long for the observed changes in the H$_3$PO$_4$$^{y–}$ to LPW O 1s signal ratio to be due to the redistribution of the ions in the electrolyte driven by a change in the charge on the BiVO$_4$ surface alone. For an ion to move 30 nm, the full thickness of the electrolyte film, under the influence of a change in field, as estimated by the change in OCP, a timescale on the order of microseconds should be observed. In addition, the timescale for changes in the surface photovoltage can vary extensively depending on the material and surface but is generally much shorter than 100s of seconds (for example in reference timescales of 6.6 μs and 1.2 ms were observed for Si(111) and ZnO(1010), respectively). Instead the observed time evolution is likely due to a chemical transformation occurring at the interface and is quite likely associated with bismuth phosphate formation. The build-up of bismuth phosphate on the BiVO$_4$ surface leads to an increase in the negative charge of the surface (either by suppression of charge recombination and/or surface polarization due to the large dipole of BiPO$_4$) and as a result leads to the redistribution of ions in the thin electrolyte film. The ions in the thin electrolyte film react effectively instantaneously to a change in charge of the surface (see above), the timescale
for which depends on the timescale for bismuth phosphate formation. The reversibility of the light-driven process is clear once the dark conditions are restored (Figure 4d). The half-cell OCP shifts toward positive values whereas the $H_3PO_4^{2-}$ to LPW O 1s signal ratio decreases.

Concomitant with the formation of bismuth phosphate, an increase in both the anion (phosphate) and cation ($K^+$) AP-HAXPES signals is observed when going from dark to light conditions at the half-cell OCP (see Figures 2b (O 1s signal from the phosphate anions), 3a and 3c (K 2p and P 2p signals, respectively)). An increase in the $K^+$ signal upon illumination may seem counter-intuitive since the surface becomes more negatively charged upon illumination. In a point charge model of the electrolyte the $K^+$ ions should then be more attracted to the surface and their AP-HAXPES signal should decrease. However, previous studies have shown that phosphate salts bearing small cations (such as $K^+$) lie at the extreme left of the Hofmeister series, have high hydration numbers (typically exceeding 10) and strong ion-pairing when dissolved in water. This means that despite the high dielectric constant of water, phosphate salts such as $KH_2PO_4$ and $K_2HPO_4$ are not completely dissociated in aqueous solution, but hydrated with ion-

**Figure 5.** Schematic rationalizing the experimental observations, dark conditions (a) and under illumination (b). Under illumination bismuth phosphate forms on the surface which is associated with the build-up of negative charge and the redistribution of ions in the 0.1 M KPi electrolyte away from the BiVO$_4$ surface.
paired configurations. This may explain the increase in $K^+$ signal. Essentially, phosphate groups bind and drag $K^+$ cations as they shift toward the electrolyte/gas interface under light conditions.

The proposed model rationalizing our experimental observations is summarized in Figures 5a and 5b. Under visible light absorption, electrochemical capacitance measurements indicate the extinction of the surface state observed in dark (surface passivation). This is likely due to a BiPO$_4$ passivation layer formed via photocorrosion followed by BiPO$_4$ precipitation. As the BiPO$_4$ layer forms, the surface becomes more negatively charged either due to a reduction in charge carrier recombination and/or a large surface dipole. This is observed by the lowering of the half-cell OCP (which passes, at steady state conditions, from $+30$ mV in dark to $-25$ mV under illumination). The timescale for this process is in the 100s of seconds. The increase in surface negative charge causes a stronger repulsive interaction between the negatively-charged phosphate anions and the surface and shifts the solvated phosphate ion distribution further away from the surface and closer to the electrolyte/gas interface (Figure 5b, light conditions), thereby increasing their AP-HAXPES signal. Due to strong ion pairing between the potassium cations and the phosphate anions the potassium ion AP-HAXPES signal also increases.

Conclusions

Combining AP-HAXPES and photoelectrochemistry techniques we have shown that the BiVO$_4$/KPi electrolyte interface undergoes a chemical modification upon absorption of visible light at the half-cell open circuit potential (OCP). Under such conditions, photocorrosion induced by illumination triggers the formation of bismuth phosphate on the surface of the BiVO$_4$ photoanode. This leads to surface passivation and the quenching of the surface state observed on undoped BiVO$_4$ under dark conditions. Moreover, the formation of bismuth phosphate is correlated with the build-up of negative charge on the surface which, in turn, causes a redistribution of ions in the thin KPi electrolyte film. We find that these changes are reversible upon restoring dark conditions. This work highlights the importance of using in situ methods to understand how working conditions play a crucial role in modulating the properties of photoanodes. For instance, the formation of a BiPO$_4$ layer forms a junction between a low band-gap oxide (BiVO$_4$, 2.4 eV) and a higher band-gap material (BiPO$_4$, 3.85 eV) and will modify the local density of states of the photoanode surface which in turn will influence device performance. We have shown that the formation of a BiPO$_4$ layer may lead to surface passivation and a recovery of the band edge pinning and a decrease in the charge recombination rate,
providing a rational for previous results reported in the literature.\textsuperscript{45, 46} In the present study, such processes are a result of a specific semiconductor/electrolyte combination and suggest that the choice of supporting electrolyte may play a significant role in photoelectrochemical device performance.

**Supporting Information**

Atomic Force Microscopy image of the BiVO\textsubscript{4} thin film, cyclic voltammetry and capacitive current scans under dark and light conditions, simulated photoelectron intensity attenuation through water layers of varying thickness, O 1s, V 2p and Bi 4f spectra of the BiVO\textsubscript{4} film in water vapor pressures of 18 Torr.

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TOC Graphics